



PTO/SB/08a/b (07-05)

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Substituted for form 1449A/B/PTO INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use as many sheets as necessary)			Complete if Known		
			Application Number	10/804640-Conf. #7762	
			Filing Date	March 19, 2004	
			First Named Inventor	Matthias WAGNER	
			Art Unit	2883	
			Examiner Name	J. P. Hughes	
Sheet	1	of	6	Attorney Docket Number	0111554.00132US3

U.S. PATENT DOCUMENTS					
Examiner Initials*	Cite No.†	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number-Kind Code² (if known)			
5H	AA*	US-4,126,396-A	11-21-1978	Hartmann et al.	
	AB*	US-4,497,544-A	02-05-1985	Mitchell et al.	
	AC*	US-4,680,085-A	07-14-1987	Vijan et al.	
	AD*	US-4,885,622-A	12-05-1989	Uchiyama et al.	
	AE*	US-4,929,063-A	05-29-1990	Durand et al.	
	AF*	US-5,037,169-A	08-06-1991	Chun	
	AG*	US-5,162,239-A	11-10-1992	Winer et al.	
	AH*	US-5,072,120-A	12-10-1991	Siewick	
	AI*	US-5,185,272-A	02-09-1993	Makiuchi et al.	
	AJ*	US-5,212,584	05/1993	Chung	
	AK*	US-5,218,422-A	06-08-1993	Zoechbauer	
	AL*	US-5,264,375-A	11-23-1993	Bang et al.	
	AM*	US-5,387,974-A	02-07-1995	Nakatani	
	AN*	US-5,408,319-A	04-18-1995	Halbout et al.	
	AO*	US-5,490,008-A	02-06-1996	Guempelein et al.	
	AP*	US-5,515,460-A	05-07-1996	Stone	
	AQ*	US-5,528,071-A	06-18-1996	Russell et al.	
	AR*	US-5,539,848-A	07-23-1996	Galloway	
	AS*	US-5,599,403-A	02-04-1997	Kariya et al.	
	AT*	US-5,619,059-A	04-08-1997	Li et al.	
	AU*	US-5,694,498-A	12-02-1997	Manasson et al.	
	AV*	US-5,708,280-A	01-13-1998	Lebby et al.	
	AW*	US-5,742,630-A	04-21-1998	Jiang et al.	
	AX*	US-5,751,757-A	05-12-1998	Jiang et al.	
	AY*	US-5,753,928-A	05-19-1998	Krause	
	AZ*	US-5,767,712-A	06-16-1998	Takemae et al.	
	AA1*	US-5,790,255-A	08-04-1998	Jackson et al.	
	AB1*	US-5,812,582	09-22-1998	Gilliland et al.	
	AC1*	US-5,814,871	09-29-1998	Furukawa et al.	
	AD1*	US-5,940,008	02/1996	Guempelein et al.	
	AE1*	US-5,942,050-A	08-24-1999	Green et al.	
	AF1*	US-5,953,355-A	09-14-1999	Kiely et al.	
	AG1*	US-6,018,421-A	01-25-2000	Cushing	
	AH1*	US-6,037,644-A	03-14-2000	Daghighian et al.	
	AI1*	US-6,075,647-A	06-13-2000	Braun et al.	
	AJ1*	US-6,091,504-A	07-18-2000	Walker et al.	
	AK1*	US-6,166,381-A	12-26-2000	Augeri et al.	
	AL1*	US-6,180,529-B1	01-30-2001	Gu	
	AM1*	US-6,194,721-B1	02-27-2001	Bly	
	AN1*	US-6,265,242-B1	07-24-2001	Komori et al.	
	AO1*	US-6,300,648-B1	10-09-2001	Mei et al.	
	AP1*	US-6,392,233-B1	05-21-2002	Channin et al.	
	AQ1*	US-6,447,126-B1	09-10-2002	Hornbeck	
	AR1*	US-6,483,862-B1	11-19-2002	Aronson et al.	
	AS1*	US-6,487,342	11-26-2002	Wu et al.	

Examiner Signature	<i>John P. Hughes</i>	Date Considered	<i>5/4</i>
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Substitute for form 1449A/B/PTO			Complete if Known		
			Application Number	10/804640-Conf. #7762	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT			Filing Date	March 19, 2004	
			First Named Inventor	Matthias WAGNER	
			Art Unit	2883	
			Examiner Name	J. P. Hughes	
Sheet	2	of	6	Attorney Docket Number	0111554.00132US3

(Use as many sheets as necessary)

AT1*	US-6,545,796-B1	04-08-2003	Greywall	
AU1*	US-6,670,599-A1	12-30-2003	Wagner et al.	
AV1*	US-6,737,648-B2	05-18-2004	Fedder et al.	
AW1*	US-6,768,097-B1	07-27-2004	Viktorovitch et al.	
AX1*	US-6,985,281-A1	08-14-2003	Wagner et al.	
AY1	US-09/813,447			
AZ1	US-09/813,449			
AA2	US-09/813,450			
AB2	US-09/813,454		Wayne et al.	
AC2	US-09/813,455			
AD2	US-09/813,456		Wagner, et al.	
AE2	US-09/813,462		Wagner, et al.	
AF2	US-60/480,294	06-20-2003	Wagner, et al.	
AG2	US-60/509,379	10-07-2003	Ma, et al.	
AH2*	US-2001/0020680	09-13-2001	Cunningham et al.	
AI2*	US-2002/0033453	03-21-2002	Sauer et al.	
AJ2*	US-2002/0080493-A1	06-27-2002	Tsai et al.	
AK2*	US-2002/0087121	05/2003	Domash et al.	
AL2*	US-2002/0105652	08-08-2002	Domas et al.	
AM2*	US-2002/0145139	10-10-2002	Wagner et al.	
AN2	US-2002/172239	11-21-2002	Chapman, B.	
AO2	US-2002/176659	11-28-2002	Colbourne et al.	
AP2	US-2002/181832	12-05-2002	Feng et al.	
AQ2*	US-2002/0185588	12-12-2002	Wagner et al.	
AR2*	US-2002/0191268-A1	12-19-2002	Seeser et al.	
AS2*	US-2003/0066967	04-10-2003	Hashimoto et al.	
AT2*	US-2003/0072009	04-17-2003	Domash et al.	
AU2*	US-2003/0087121-A1	05-08-2003	Domash et al.	
AV2*	US-2003/0132386	07-17-2003	Carr et al.	
AW2*	US-2004/0104334	06-03-2004	Carr	
AX2*	US-2003/0141453	07-31-2003	Reed, et al.	

FOREIGN PATENT DOCUMENTS							
Examiner Initials*	Cite No. ¹	Foreign Patent Document		Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T ⁴
		Country Code ³ -Number ⁴ -Kind Code ⁵ (if known)					
JL	BA	EP-0125390-A1		11-21-1984	Schaumberg Hanno		
	BB	EP-0139487		05-02-1985	Exxon Research		
	BC	EP-0178148-A2		04-16-1986	Xerox Corporation		
	BD	EP-0518228		12-16-1992	Hartmann & Braun		
	BE	EP-0559347		09-08-1993	AT&T Corp.		
	BF	EP-0773640		05-14-1997	AT&T		
	BG	EP-0901170		03-10-1999	Sumitomo Electric Industries		
	BH	EP-1055959		11-29-2000	NEC Corporation		
	BI	EP-0859413		08-19-1998	Mitsubishi		
	BJ	EP-0860885		08-26-1998	Canon Kabushiki Kaisha		
	BK	EP-0883194-A1		12-09-1998	Univ Roma		
	BL	EP-0899836-A1		03-03-1999	Xerox Corporation		
	BM	EP-0899835-A1		03-03-1999	Xerox Corporation		

Examiner Signature		Date Considered	3-30-01
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		Art Unit	2883		
		Examiner Name	J. P. Hughes		
Sheet	3	of	6	Attorney Docket Number	0111554.00132US3

JH	BN	DE-4424717	01-19-1996	Siemens Aktiengesellschaft	
	BO	DE-196 35 583	03-05-1998	Siemens AG	✓
	BP	JP-07168040	07-04-1995	Nippon Steel Corp.	
	BQ	JP-08250551	09-27-1996	Mitsubishi Elec. Corp.	
	BR	JP-60210826	10-23-1985	Mitsubishi Elec. Corp.	
	BS	WO-89/03593	04-20-1989	Stemcor Corp.	
	BT	WO-99/30394	06-17-1999	Coherent, Inc.	
	BU	WO-00/13350	03-09-2000	E-TEK Electrophotonics Solutions Corporation	
	BV	WO-00/22479	04-20-2000	Siemens Aktiengesellschaft	
	BW	WO-00/23833	04-27-2000	Coretek Inc.	
	BX	WO-01/16637	03-08-2001	Epitaxx Inc.	
	BY	WO-01/67646	09-13-2001	Flanders et al	
	BZ	WO-01/73850	10-04-2001	Aegis Semiconductor Inc.	
	BA1	WO-02/50528	06-27-2002	Baltes et al.	
	BB1	WO-02/057180	07-25-2002	Honeywell International, Inc.	
	BC1	WO-02/103441	12-27-2002	Aegis Semiconductor Inc.	✓
J	BD1	WO-03/046630	06-05-2003	Aegis Semiconductor Inc.	

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. * CITE NO.: Those application(s) which are marked with an single asterisk (*) next to the Cite No. are not supplied (under 37 CFR 1.98(a)(2)(ii)) because that application was filed after June 30, 2003 or is available in the IFW. ¹ Applicant's unique citation designation number (optional). ² See Kinds Codes of USPTO Patent Documents at www.uspto.gov or MPEP 901.04. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. ⁶ Applicant is to place a check mark here if English language Translation is attached.

NON PATENT LITERATURE DOCUMENTS				
Examiner Initials	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²	
JH	CA	AUGUSTINE, B.H. et al. "Thermal-optical switching of a silicon based interference filter" J. Appl. Phys. (15 February 1994): 75(04) 1875-1877		
	CB	BAUMEISTER, P., "Simulation of a rugate filter via a stepped-index dielectric multilayer", <i>Applied Optics</i> , Vol. 25, No. 16, pp. 2644-2645, 1986		
	CC	BRUEL et al., "Smart-cut: A New Silicon on Insulator Material Technology based on Hydrogen Implantation and Wafer Bonding", <i>Jpn. J. Appl. Phys.</i> , Vol. 36, pp. 1636-1641, 1997		
	CD	CARBUNESCU, E. "Non linear optical effects in hydrogenated amorphous silicon" <i>Optical Engineering</i> , Vol. 35, No. 05, pp. 1322-1324, May 1996		
	CE	CHOI et al. "Design and Control of a Thermal Stabilizing System for a MEMS Optomechanical Uncooled Infrared Imaging Camera", <i>Sensors and Actuators</i> , Vol. 203, No. A104, pp. 132-142		
	CF	COCORULLO, G. et al. "Amorphous silicon based waveguides and light modulators for silicon low-cost photonic integrated circuits." <i>MRS Fall Meeting Boston</i> (December 1997)		
	CG	COCORULLO, G. et al. "Amorphous silicon waveguides and light modulators for integrated photonics realized by low-temperature plasma-enhanced chemical-vapor deposition." <i>Optics Letters</i> , Vol. 21, No. 4, pp. 2002-2004, 15 December 1996		
	CH	COCORULLO, G. et al. "Amorphous silicon-based guided-wave passive and active devices for silicon integrated optoelectronics." <i>IEEE Journal of Selected Topics in Quantum Electronics</i> , Vol. 4, No. 6, pp. 997-1002, Nov/Dec 1998		
	CI	COCORULLO, G. et al. "Amorphous silicon waveguides and interferometers for low-cost silicon optoelectronics." <i>SPIE</i> , Vol. 3278, pp. 286-292, 1998		
	CJ	COCORULLO, G. et al., "Measurement of the thermo-optic coefficient of a-Si:H at the		
Examiner Signature	<i>[Signature]</i>		Date Considered	3-3-06

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Sheet	4	of	6	Attorney Docket Number	0111554.00132US3

JK		wavelength of 1500 nm from room temperature to 200°C", <i>Journal of Non-Crystalline Solids</i> , pp. 310-313, 2002	
JK	CK	COCORULLO et al., "Fast Infrared Light Modulation in a-Si:H Micro-devices", <i>J. Non-Crystalline Sol.</i> , Vol. 266, pp. 1247-1251, 2000	
	CL	COCORULLO, G. et al. "Silicon thermo-optical micromodulator with 700-KHz-3dB bandwidth." <i>IEEE Photonics Technology Letters</i> , Vol. 7, No. 4, pp. 363-365, April 1995	
	CM	COPPOLA, G. et al. "Simulation and analysis of a high-efficiency silicon optoelectronic modulator based on a Bragg mirror." <i>Society of Photo-optical Instrumentation Engineers</i> (June 2001): 40(6) 1076-1081	
	CN	DELLA CORTE, F. et al., "Study of the thermo-optic effect in hydrogenated amorphous silicon and hydrogenated amorphous silicon carbide between 300 and 500 K at 1.55 μ m", <i>Applied Physics Letters</i> , Vol. 79, No. 2, pp. 168-170, 9 July 2001	
	CO	DESALVO et al., "Advanced Components and Subsystem Solutions for 40 gb/s Transmission", <i>Journal of Lightwave Technology</i> , Vol. 20, No. 12, pp. 2175-2177, 2002	
	CP	DOMASH et al., "Broadly Tunable Thin Film Interference Coatings: Active Thin Film for Telecom Applications", <i>Proceedings of SPIE</i> , Vol. 4989, pp. 161-167, June 2003	
	CQ	DOMASH, L. et al., "Switchable thin film add/drop filter", <i>2003 Optical Society of America</i> , PD35-1-PD25-3, 2003	
	CR	DOMASH, L. et al., "Tunable thin-film filters based on thermo-optic semiconductor films", <i>Applications of Photonic Technology 5, Proceedings of SPIE</i> , Vol. 4833, pp. 685-695, 2002	
	CS	DOMASH et al., "Tunable and Switchable Multiple-Cavity Thin Film Filters", <i>Journal of Lightwave Technology</i> , Vol. 22, No. 1, pp. 126-135, 2004	
	CT	EICKER, U. et al. "Optical bistability in amorphous Si-C alloys and amorphous alloy interference filters." <i>Optical Society of America</i> , Vol. 8, No. 3, pp. 614-617, 1991	
	CU	FERNANDES, M. et al., "VIS/NIR detector based on μ c-Si:H p-i-n structures", <i>Thin Solid Films</i> , Elsevier Science, S.A., Vol. 364, No. 1-2, pp. 204-205, March 2000	
	CV	GHOSH, G., "Temperature dispersion of refractive indices in crystalline and amorphous silicon", <i>Appl. Phys. Lett.</i> 66, Vol. 26, 26 June 1995	
	CW	GNAUCK et al., "Optical Equalization of Fiber Chromatic Dispersion in a 5-GB/S Transmission System", <i>IEEE Photonics Technology Letters</i> , Vol. 2, No. 8, pp. 585-587, 1 August 1990	
	CX	HOHLFELD et al., "A Thermally Tunable Silicon-based Optical Filter", <i>Sensors and Actuators</i> , Vol. 103, No. 1-2, pp. 93-99, 15 January 2003	
	CY	HOHLFELD et al., "Thermally Tunable Optical Filter Array", <i>Proceedings of SPIE - Optical Devices for Fiber Communication IV</i> , Vol. 4989, pp. 143-154, June 2003	
	CZ	IODICE, M. et al. "Simple and low-cost technique for wavelength division multiplexing channel monitoring." <i>Society of Photo-Optical Instrumentation Engineers</i> , Vol. 69, No. 6, pp. 1704-1711, June 2000	
	CA1	JABLONSKI, M. et al., "Entirely thin-film allpass coupled-cavity filters in a parallel configuration for adjustable dispersion-slope compensation", <i>IEEE Photonics Technology Letters</i> , Vol. 13, No. 11, November 2001	
	CB1	JDSU COADM Configurable Optical Add Drop Multiplexers, http://www.jdsu.com/site/images/products/pdf/coadm_apnote.pdf	
	CC1	KAJAVA, T. et al. "Tunable fabry-perot micro-filters for telecommunication system diagnostics." <i>Tech Dig. Conf. Lasers and Electro-Optics Cleo/Europe</i> , p. 324, 1998	
	CD1	KOBAYASHI, Y. et al., "Improvement on Coupling Efficiency for Passive Alignment of Stacked Multi-Fiber Tapes to a Vertical-Cavity Surface-Emitting Laser Array", <i>Extend Abstracts of the 1996 International Conference on Solid State Devices and Materials</i> , pp. 655-657, 1996	
	CE1	LEQUIME, M. et al., "Toward tunable thin-film filters for wavelength division multiplexing applications", <i>Applied Optics</i> , Vol. 41, No. 16, pp. 3277-3284, 1 June 2002	
	CF1	LI, H., "Refractive Index of Silicon and Germanium and its Wavelength and Temperature	

Examiner
Signature

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Date
Considered

3-30-07

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		Filing Date	March 19, 2004		
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		Art Unit	2883		
		Examiner Name	J. P. Hughes		
Sheet	5	of	6	Attorney Docket Number	0111554.00132US3

		Derivatives", <i>J. Phys. and Chem. Ref. Data.</i> , Vol. 9, p. 561, 1980	
JH	CG1	LUNARDI, L. et al., "Tunable dispersion compensation at 40-Gb/s using a multicavity etalon all-pass filter with NRZ, RZ and CS-RZ modulation", <i>Journal of Lightwave Technology</i> , Vol. 20, No. 12, December 2002	
	CH1	MADSEN et al., "A Multi-Channel Dispersion Slope Compensating Optical Allpass Filter", <i>Optical Fiber Communication Conference, Technical Digest Postconference edition</i> , Vol. 2 of 4, pp. WF5-1, 7 March 2000	
	CI1	MADSEN et al., "A Tunable Dispersion Compensating MEMS All-Pass Filter", <i>IEEE Photonics Technology Letters</i> , Vol. 12, No. 6, pp. 651-653, 2000	
	CJ1	MANDURAH, M.M., "Dopant Seregation in Polycrystalline Silicon", <i>J. App. Phys.</i> , Vol. 51, pp. 5755-5763, 1980	
	CK1	MARTINU, L., "Plasma deposition of optical films and coatings: A review", <i>J. Vac. Sci. Technol.</i> , Vol. 18, No. 6, pp. 2619-2645, Nov./Dec. 2000	
	CL1	MOSS et al., "Multichannel Tunable Dispersion Compensation Using all-pass Multicavity Etalons", <i>Optical Society of America</i> , 2002	
	CM1	NIEMI, T. et al. "Tunable silicon etalon for simultaneous spectral filtering and wavelength monitoring of a DWDM transmitter." <i>IEEE Photonics Technology Letters</i> (January 2001): 13(1) 58-60	
	CN1	ODEN et al., "Uncooled Thermal Imaging Using a Piezoresistive Microcantilever", <i>Health Science Research Division, Oak Ridge National Laboratory</i> , (3 pages), 1996	
	CO1	PANGAL, K. et al., "Hydrogen plasma enhanced crystallization of hydrogenated amorphous silicon films", <i>Journal of Applied Physics</i> , Vol. 85, No. 3, pp. 1900-1906, 1 February 1999	
	CP1	PARMENTIER, R. et al., "Towards tunable optical filters", <i>Technical Digest, OSA Topical Meeting Optical Interference Coatings</i> , Paper WB1, 15 July 2001	
	CQ1	PARMENTIER, R. et al., "Substrate-strain-induced tunability of dense wavelength-division multiplexing thin-film filters", <i>Optic Letters</i> , Vol. 28, No. 9, pp. 728-730, 1 May 2003	
	CR1	PAYNE et al., "Effects of Chlorine on Dopant Activation in α -Si:H", <i>Appl. Phys. Lett.</i> , Vol. 76, No. 20, p. 2949, 2000	
	CS1	POLYAKOV et al., "Processability and Electrical Characteristics of Glass Substrates for RF Wafer-Level Chip-Scale Packages", <i>2003 Proceedings 53rd, Electronic Components and Technology Conference</i> , Vol. CONF. 53, 27 May 2003	
	CT1	RIANT et al., "Chirped Fiber Bragg Gratings for WDM Chromatic Dispersion Compensation in Multispan 10-Gb/s Transmission", <i>IEEE Journal of Selected Topics in Quantum Electronics</i> , Vol. 5, No. 5, pp. 1312-1323, 1999	
	CU1	SCHMIDT, M. A., "Wafer-to-wafer Bonding for Microstructure Formation", <i>Proc. IEEE</i> , Vol. 86, pp. 1575-1585, 1998	
	CV1	SONG et al., "Fabrication of Single Crystalline Silicon on Glass by Smart-Cut Technique", <i>Chinese Physics Letters</i> , Vol. 20, No. 1, pp. 108-110, January 2003	
	CW1	TAKAGI et al., "High-rate Growth of Stable α -Si:H", <i>Mat. Res. Soc. Symp. Proc.</i> , Vol. 557, p. 105, 1999	
	CX1	TAKASHASHI, H., "Temperature stability of thin-film narrow-bandpass filters produced by ion-assisted deposition", <i>Applied Optics</i> , Vol. 34, No. 4, pp. 667-675, 1 February 1995	
	CY1	TSAI, RY. et al., "Amorphous silicon and amorphous silicon nitride films prepared by a plasma-enhanced chemical vapor deposition process as optical coating materials", <i>Applied Optics</i> , Vol. 32, No. 28, pp. 5561-5566, 1 October 1993	
	CZ1	WILLNER, A., "Chromatic dispersion and polarization-mode dispersion", <i>OPN TRENDS</i> , pp. S-16-S-21, March 2002	
	CA2	WPIEJEWSKI et al., "Vertical-Cavity Surface-Emitting Laser Diodes for Short Distance Optical Fiber Networks", <i>Proceeding of the Electronic Components and Technology Conference, Washington DC, IEEE</i> , Vol. 44, pp. 330-334, 1994	

Examiner Signature		Date Considered	3-30-06
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				Examiner Name	J. P. Hughes
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072	CB2	YANG et al., "Amorphous Silicon and SiGe Alloy Solar Cells Deposited by VHF", <i>Mat. Res. Soc. Symp.</i> , Vol. 664, p. A11.3.1, 2001	
072	CC2	ZHAO et al., "Optomechanical Uncooled Infrared Imaging System: Design, Microfabrication, and Performance", <i>Journal of Microelectromechanical Systems</i> , Vol. 11, No. 2, pp. 136-146, 2002	

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹Applicant's unique citation designation number (optional). ²Applicant is to place a check mark here if English language Translation is attached.

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